

FAST-Resistor wso 11

三三三

第六章 俗文化研究：中華文化復興運動

卷之三

Digitized by srujanika@gmail.com

1

100

三

Drafts

1

14 and (second period floating).cml

Serial No.	Document ID	Issue Date	Pages	Title	Current CR	Current XN	Retrieval	Inventor	S	C	E	W	M
134	P, F, G, P, US 5429970	19950704	A	Method of making flash EEPROM memory cell	438/259	257/316; 257/E21.68		Hong, Gary	F	G	F	G	
135	P, F, G, P, US 5413946	19950509	A	Method of making flash memory cell with self-aligned vertical	438/261	257/316; 257/E21.42		Hong, Gary	C	F	F	C	
136	P, F, G, P, US 5380672	19950110	A	Dense vertical programmable read only memory cell	438/257	257/E27.10		Yuan, Jack H. et al.	F	G	F	G	
137	P, F, G, P, US 5315142	19940524	A	High performance trench EEPROM cell	257/316	257/321; 257/513		Acovic, Alexandre et al.	F	G	F	G	
138	P, F, G, P, US 5238855	19930824	A	Cross-point contact-free array with	438/261	257/E27.10		Gill, Manzur	C	F	F	C	
139	P, F, G, P, US 5225361	19930706	A	Non-volatile semiconductor memory device	438/264	257/E21.42		Kakiuchi, Takao et al.	F	G	F	G	
140	P, F, G, P, US 5135879	19920804	A	Method of fabricating a high density EEPROM cell	438/259	148/DIG.16		Richardson, William L.	F	G	F	G	
141	P, F, G, P, US 5087584	19920211	A	Process for fabricating a contactless floating	438/262	148/DIG.50		Weda, Glen N. et al.	C	F	F	C	
142	P, F, G, P, US 5087583	19920211	A	Process for EEPROM cell structure and architecture	438/260	257/E29.30		Hazani, Emanuel	F	G	F	G	
143	P, F, G, P, US 5017977	19910521	A	Dual EEPROM cells on trench walls with virtual	257/316	257/331; 257/E27.10		Richardson, William L.	F	G	F	G	
144	P, F, G, P, US 4990979	19910205	A	Non-volatile memory cell	257/321	257/316; 257/397		Otto, Joachim	F	G	F	G	